Semiconductors ECE 320 Electronics I (Digital Electronics) Jake Glower - Lecture #4

Please visit Bison Academy for corresponding lecture notes, homework sets, and solutions

Semiconductors

Silicon is a key element for many electronics devices

It has properties that are very different from other elements like metals

- Metals
 - Resistance goes up as temperature goes up
 - Only one type of charge carrier (electrons)
- Semiconductors (Silicon)
 - Resistance goes down as temperature goes up
 - Two types of charge carriers (holes and electrons)
- Lecture Topics
 - Why does silicon behave this way?
 - What are electrons and holes?
 - What can you do with silicon?





Noble Gasses: Column VIIIA

All electron shells filled

- No desire to give up an electron
- No desire to accept more electrons

These elements

- Do not interract with other atoms
- Do not conduct electricity
 - No free charge carriers



Halogens and Nonmetals

Column VIA and VIIA

Example: F_2 , O_2 , N_2

One to three electrons short of filling all orbitals

• Forms a covalent bond with another atom

Resulting molecule is similar to a Noble gas

- Gas (low molecular weight)
- Does not conduct electricity
- (No free electrons)







Metals

- Column IA, IIA, IIIA
 - Sodium, Magnesium, Aluminum
- Core is a Noble gas (Neon)
 - Has excess electrons
 - These electrons are loosely tied to the atom
 - They are free to move in the conduction bands



electrons tied to atom

Properties of Metals

- One type of charge carrier
 - Electrons in the conduction band
- Resistance goes up as temperature goes up
 - Can be used to measure temperature
 - RTD (resitive thermal device)

Be	a = 2.5%/C	most sensitive
Ni	a = 0.681%/C	
Fe	a = 0.651%/C	
Cu	a = 0.43%/C	
AI	a = 0.429%/C	
Pt	a = 0.385%/C	
Nd	a = 0.16%/C	least sensitive

 $R = (1 + \alpha T) \cdot R_0$

Silicon

Column IVA of the periodic chart

- 4 electrons in its outer shell
- Forms a covalent bond with 4 neighbors
- Resulting crystal has no free electrons
 - At 0K silicon is an insulator



Electrons and Holes

Silicon has two ways to carry charge: electrons and holes.

- Above 0K, some of the electrons in their covalent bonds will break free due to thermal energy.
- Once free, the electron is free to move about the crystal, carrying current with a negative charged carrier.
- The covalent bond which is missing an electron acts like a positive charge carrier, termed a hole.



Mobility of Holes and Electrons

The mobility of electrons and holes are different - with electrons being more free to move about (and likewise have a lower resistance)

$$\mu_n = 1300 \frac{cm^2}{Vs}$$
$$\mu_p = 500 \frac{cm^2}{Vs}$$

Meaning:

• n-type silicon has lower resistance than p-type silicon

or

• p-type silicon requires 2.6x heavier doping to get the same resistance

From a practical standpoint, it doesn't matter

- You can make resistors out of n-type or p-type silicon
- The doping concentration is so low that 2.6x isn't significant

Problem: Find the resitivity of Silicon at 300K:

Solution: The conductivity is due to electrons and holes, which are both 1.5×10^{10} / cc

$$\sigma = n_i q(\mu_n + \mu_p) = (1.66 \cdot 10^{11} cm^{-3})(1.6x 10^{-19} C)(1300 + 500) \frac{cm^2}{Vs}$$

 $\sigma = 4.78 \times 10^{-5} \frac{1}{\Omega cm}$ $\rho = \frac{1}{\sigma} = 20,917\Omega \cdot cm$

which makes pure silicon a poor conductor:

Example: Find the resistance of a piece of silicon at 293K with a length of 1mm and a cross sectional area of 0.5mm x 0.5mm (an 0402 resistor)

Solution:

$$R = \frac{\rho L}{A} = \frac{(20,917\Omega \cdot cm)(0.1cm)}{(0.05cm)^2} = 836k\Omega$$

Thermal Properties of Silicon

Above 0K, some electrons can escape the covalent bond:

$$n_i^2 = A_o T^3 e^{-E_G'/kT}$$

- EG is the energy gap at 0K
- k is Boltzmann's constant
- $A_0 = 2.36 \cdot 10^{33}$

For Silicon:

 $E_G \approx 1.2 - 0.00036T$ eV or at 300K,

$$E_G = 1.1 eV$$

$$k = 8.617343 \times 10^{-5} \frac{eV}{K}$$

$$np = n_i^2 \approx (1.70 \cdot 10^{11})^2$$



Thermistors:

Problem: Design an 0402 resistor with Silicon doped at 10^{16} /cc sandwiching a small section of intrinsic Si. Specify the width of the intrinsic Silicon so that the resistor has a resistance of 1k at 25C.



Assume a doping of $n=10^{16}/cc$ for the n-type Silicon. This results in a resistance of 19 Ohms from the previous analysis. Ignoring this (since it's much less than 1k), the ressistance of the intrincic Silicon needs to be 1k.

At 273K,

$$\rho = \frac{1}{\sigma} = 20,917\Omega \cdot cm$$

$$R = 1000 = \frac{\rho L}{A}$$

$$1000 = \frac{(20,917\Omega \cdot cm)(x)}{(0.05cm)^2}$$

$$x = 119\mu m$$

Add a thin strip of intrinsic Silicon in the middle of the resistor and the resistance rises to 1k Ohm.

Note that the resulting resistor is sensitive to temperature:

$$n_i^2 = A_o T^3 e^{-E'_G/kT}$$

$$\sigma = q(n\mu_n + p\mu_p) = (1.6x10^{-19}C)(n_i)(1300 + 500)\frac{1}{\Omega \cdot cm}$$

$$A_0 = 2.36 \cdot 10^{33}$$

$$E_G = 1.1eV$$

$$k = 8.617343 \times 10^{-5} \frac{eV}{K}$$

In Matlab you can plot the resistance vs. temperature:

• The intrinsic carrier concentration, ni, varies considerable from -40C to +40C.

```
C = [-40:40]';
T = C + 273;
Ao = 2.36e33;
Eg = 1.2 - 0.00036*T;
k = 8.617343e-5;
ni = sqrt( Ao*(T.^3).*exp(-Eg./(k*T)));
plot(C,ni)
xlabel('Celsius');
ylabel('ni')
```



Likewise, the resistance across this 119um strip of Silicon varies with temperature:

- This is a temperture-sensitive resistor, termed a thermistor.
- By measuring its resistance, you know the temperature.

```
sigma = (1.6e-19)*(ni)*(1800);
p = 1 ./ sigma;
R = p*(119e-6) / (0.05^2);
```

```
plot(C,R)
xlabel('Celsius');
xgrid(5)
ylabel('Ohms');
```



Doping

You can change the resistance of silicon by doping. For silicon, the product np is constand:

$$np = n_i^2$$

In p-type silicon, you dope the silicon with Boron, with a typical doping of 10^{16} atoms per cc. In this case, most of the holes will be due to the doping:

$$p \approx 10^{16}/\mathrm{cc}$$

with just a few due to thermal electrons:

$$n = \left(\frac{n_i^2}{p}\right) = 2.25 \cdot 10^5 / \text{cc}$$



The resistance of the same piece of sillcon doped with Boron is:

$$\sigma = q(n\mu_n + p\mu_p) = (1.6x10^{-19}C)(2.25x10^5 \cdot 1300 + 10^{16} \cdot 500)\frac{cm^2}{Vs}$$

$$\sigma \approx qp\mu_p = (1.6x10^{-19}C)(10^{16} \cdot 500)\frac{cm^2}{Vs}$$

$$\sigma = 0.8\frac{1}{\Omega cm}$$

$$\rho = \frac{1}{\sigma} = 1.25\Omega \cdot cm$$

The resistivity is 184,000 times smaller, resulting in the resistance of the silicon being 184,000 times lower:

$$R = \frac{\rho L}{A} = \frac{(1.25\Omega \cdot cm)(0.1cm)}{(0.05cm)^2} = 50\Omega$$

If you dope the silicon with phosphorus, (an element with 5 electrons in its outer shell), the crystal will have extra electrons. This creates n-type silicon:

$$n \approx 10^{16}/cc$$
$$p = \frac{n_i^2}{n} = 2.25 \cdot 10^5/cc$$

In n-type silicon, the doping is Phosphorus, resulting in

$$n_n \approx 10^{16}$$
$$p_n = 2.25 \cdot 10^5$$

and the resistivity and resistance is:

$$\sigma = q(n\mu_n + p\mu_p) = (1.6x10^{-19}C)(10^{16} \cdot 1300 + 2.25x10^5 \cdot 500)\frac{cm^2}{Vs}$$

$$\sigma \approx qn\mu_n = (1.6x10^{-19}C)(10^{16} \cdot 1300)\frac{cm^2}{Vs} + 2.08\frac{1}{\Omega cm}$$

$$\rho = \frac{1}{\sigma} = 0.481\Omega \cdot cm$$

$$R = \frac{\rho L}{A} = \frac{(0.481\Omega cm)(0.1cm)}{(0.05cm)^2} = 19.2\Omega$$

Observations:

- n-type silicon has slightly lower resistance than p-type silicon with the same doping. This doesn't matter that much since you can increase the doping concentration of p-type material to compensate for this.
- It's fairly easy to build resistors out of silicon: just vary the doping concentration.
- The intrinisic carrier concentration varies with temerature. At high temperatures, there are more charge carriers. This allows you to use silicon as a temperature sensor, where resistance drops with temperature. Such sensors are called thermistors (thermal resistors).

Semiconductor Resistors:

Problem: Design an 0402 resistor with a R = 1000 Ohms.

Why? Resistors are pretty useful devices. By varying the doping, you can vary the resistance of a piece of Silicon.

Solution: The resistivity you want is

$$R = \frac{\rho L}{A} = \frac{(\rho \ \Omega cm)(0.1 cm)}{(0.05 cm)^2} = 1000\Omega$$

$$\rho = 25\Omega \cdot cm$$

$$\sigma = 0.04 \frac{1}{\Omega \cdot cm}$$

$$\sigma \approx qn\mu_n = (1.6x10^{-19} C)(n \cdot 1300) \frac{cm^2}{Vs} = 0.04 \frac{1}{\Omega \cdot cm}$$

$$n = 1.9 \cdot 10^{14} / cm^3$$

Dope the Silicon with Phosphorus with a concentration of $1.9 \cdot 10^{14}$ Phosphorus atoms per cubic centimeter. The resulting resistor will have a resistance of 1k Ohm.



Problem: Design a 10k resistor.

Solution: If the doping is 10 times lower, you'll have 10 times fewer charge carriers, and hence, 10 times the resistance.

 $n = 1.9 \cdot 10^{13} / cm^3$

It's pretty easy designing resistors with Silicon.



Summary

Semiconductors are different than metals

- Their resistance drops as temperature increases
 - Allows you to build thermistors
- They have two types of charge carriers
 - electrons
 - holes

With doping, you can

- Set the resistance of a piece of silicon
- Make it an n-type semiconductor
 - Almost all of the charge carriers are electrons
- Make it a p-type semiconductor
 - Almost all of the charge carriers are holes